Supporting Information for

In Situ Fabricated Cu-Ag Nanoparticle - Embedded Polymer Thin Film as an Efficient Broad Spectrum SERS Substrate

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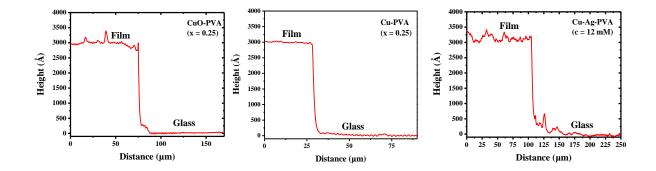
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Thickness of the Nanocomposite Films

Thickness of the different films fabricated as described in the main text was measured using an Ambios Technology XP-1 Profilometer.

Figure S1. The line profiles recorded across a sharp edge of the film with respect to the substrate; thickness of the film is found to be ~ 300 nm in all cases.



Estimation of the Cu-Ag Composition

ICP analysis of the metal content

Cu-PVA and Cu-Ag-PVA (fabricated using AgNO₃ solution of concentration, c) and Ag-PVA thin films coated on a 3×1 cm² quartz plate were dissolved in 69% nitric acid. The solution was diluted to 100 ml and ICP-OES analysis was carried out.

Table S1. Content of Cu and Ag in the Cu-PVA and Cu-Ag-PVA (fabricated using AgNO₃ solution of concentration, c) thin films determined using ICP-OES.

Substrate			content m (µmol)	Atom % in the film	
		Cu	Ag	Cu	Ag
Cu-PVA		0.6590	0	100	0
Cu-Ag-PVA	1	0.6987	0.1954	78	22
[c (mM)]	6	0.4572	0.3888	54	46
	9	0.3632	0.4432	45	55
	12	0.2931	0.5431	35	65
Ag/PVA	0.5	0	0.3770	0	100
	1.0	0	0.8292	0	100

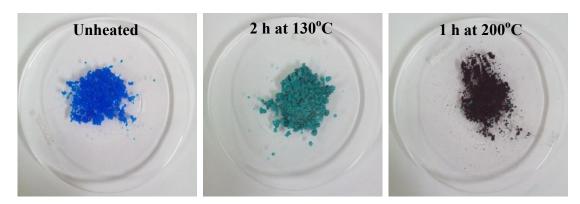
Table S2. Cu-Ag compositions of Cu-PVA and Cu-Ag-PVA (fabricated using AgNO₃ solution of concentration, c) thin films estimated by ICP-OES analysis, compared with that obtained from EDX spectroscopy analysis in TEM and FESEM.

	Atom%							
Substrate		ICP-OES		EDX (TEM)		EDX (FESEM)		
		Cu	Ag	Cu	Ag	Cu	Ag	
Cu-PVA		100	0	100	0	100	0	
Cu-Ag-PVA	1	78	22	71	29	70	30	
[c (mM)]	3	-	-	56	44	62	38	
	6	54	46	34	66	45	55	
	9	45	55	24	76	28	72	
	12	35	65	19	81	24	76	

Decomposition of Cu(NO₃)₂·3H₂O

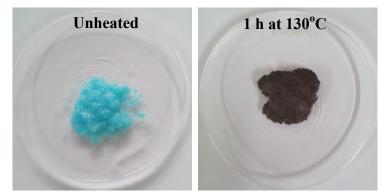
Decomposition of $Cu(NO_3)_2.3H_2O$ was examined by heating the pure salt as well as its solid mixture with poly(vinyl alcohol) (PVA) at different temperatures.

Figure S2. Photographs of $Cu(NO_3)_2 \cdot 3H_2O$ heated under different conditions.



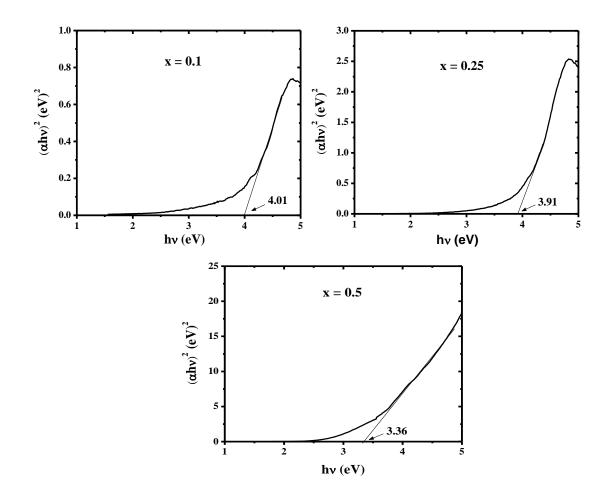
Color change observed in the sample heated at 130°C is due to the formation of basic copper nitrate and the black material obtained when heated at 200°C is cupric oxide (confirmed by powder X-ray diffraction experiment and comparison to JCPDS 75-1779 [Cu₂(OH)₃(NO₃)] and 89-5897 [CuO] respectively). See also: H. W. Richardson, Ullmann's Encyclopedia of Industrial Chemistry, Wiley 2012, p 273.

Figure S3. Photographs of $Cu(NO_3)_2 \cdot 3H_2O+PVA$ heated under different conditions.



Formation of the black solid at 130° C suggests that the presence of PVA lowers the temperature of decomposition of Cu(NO₃)₂.3H₂O and formation of CuO.

Figure S4. Tauc plots for the direct band gap of the CuO-PVA film with different values of Cu/PVA weight ratio (x).



AFM Images of the CuO-PVA and Cu-PVA Thin Films

AFM images were taken on CuO-PVA and Cu-PVA thin films to examine the average roughness of the films; an NT-MDT model Solver Pro-M AFM in semi-contact mode with a cantilever having a force constant of 11.8 N/m was used.

The average roughness of both films were found to be ≤ 0.5 nm.

Figure S5. AFM images and histogram of the surface (height) roughness of CuO-PVA and Cu-PVA thin films.

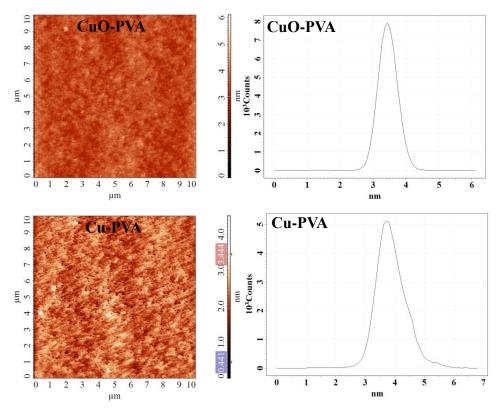


Table S3. Average roughness with standard deviation (σ) inferred from the AFM images taken at 5 different regions (10 × 10 μ m²) on the CuO-PVA and Cu-PVA thin films.

Imaga	Average roughness (nm)			
Image	CuO-PVA	Cu-PVA		
1	0.63	0.44		
2	0.24	0.40		
3	0.65	0.41		
4	0.26	0.55		
5	0.34	0.69		
Average for the	0.42 (0.20)	0.50 (0.12)		
5 measurements (σ)	0.42 (0.20)	0.30 (0.12)		

Extinction Spectra of the Cu-PVA, Cu-Ag-PVA and Ag-PVA Thin Films

Figure S6. Extinction spectra of the Cu-PVA and Cu-Ag-PVA thin film formed by treatment with different concentrations (c) of AgNO₃ solutions (part of this figure relevant to the main study is provided in Figure 5 of the main text).

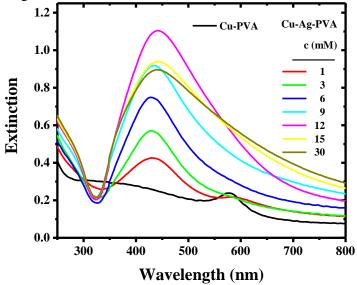
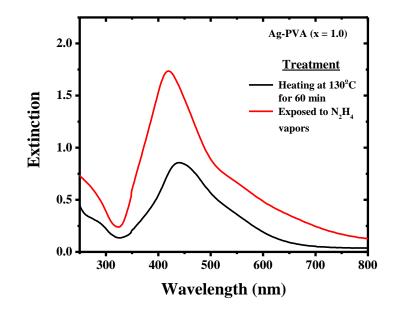
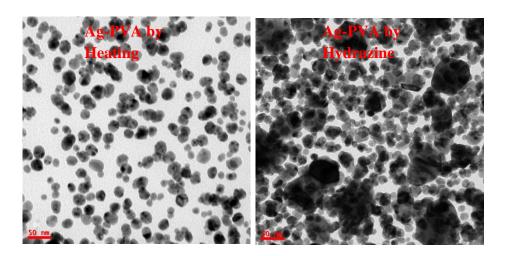


Figure S7. Extinction spectra of Ag-PVA fabricated with weight ratio (Ag/PVA) = 1.0, by thermal treatment and exposing to hydrazine hydrate vapors at room temperature (~28°C).



TEM Images of the Ag-PVA Thin Films

Figure S8. TEM images (scale = 50 nm) of Ag-PVA fabricated with weight ratio (Ag/PVA) = 1.0, by thermal treatment and exposure to hydrazine hydrate vapors at room temperature ($\sim 28^{\circ}$ C).



Electron Diffraction of the Cu-PVA, Cu-Ag-PVA and Ag-PVA Thin Films

CuO-PVA and Cu-PVA thin films

Table S4. Indexing of the electron diffraction patterns recorded for the CuO-PVA and Cu-PVA thin films (Fig. 3c and 4c of the main text), based on the monoclinic structure of CuO and fcc structure of Cu.

ED pattern in	d (Å)	h k l
	2.76	1 1 0 (CuO)
Fig. 3c	2.50	1 1 1 (CuO)
	1.48	1 1 3 (CuO)
	2.10	1 1 1 (Cu)
Fig. 4c	1.81	2 0 0 (Cu)
r 1g. 40	1.28	2 2 0 (Cu)
	1.07	3 1 1 (Cu)

Cu-Ag-PVA thin films

Table S5. Indexing of the electron diffraction pattern recorded for the Cu-Ag-PVA thin film (Fig. 6 of the main text), based on fcc structures of Cu and Ag.

d (Å)	h k l
2.34	111(Ag)
2.10	1 1 1 (Cu)
2.04	200(Ag)
1.82	200(Cu)
1.43	220 (Ag)
1.23	2 2 0 (Cu)
1.23	311(Ag)
1 04	2 2 2 (Cu)
1.04	400(Ag)

- CuO: JCPDS file no: 89-2531
- Cu: JCPDS file no: 01-1242
- Ag: JCPDS file no: 01-1164

X-ray Photoelectron Spectra

XPS of CuO-PVA, Cu-PVA and Cu-Ag-PVA (prepared with c = 12 mM) thin films were recorded on a VG Microtech, model ESCA 3000 instrument equipped with ion gun (EX-05) for cleaning the surface; the binding energy resolution was 0.1 eV. Un-monochromatized Al K_{α} radiation (photon energy = 1486.6 eV) was used where the electron take off angle (angle between electron emission direction and surface plane) was 60°. The core level binding energies were fixed with the carbon binding energy of 284.8 eV. Baseline corrected spectra with peak deconvolution are shown below.

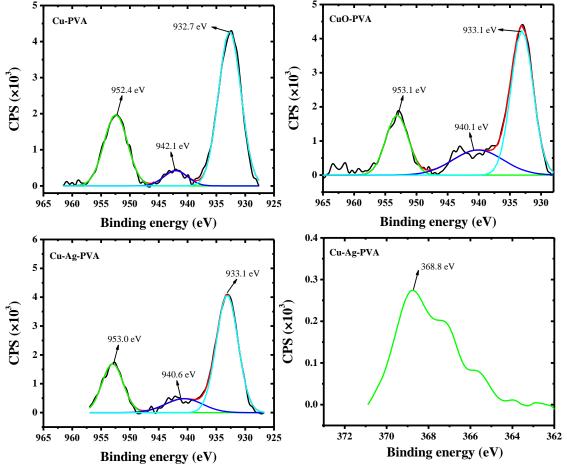
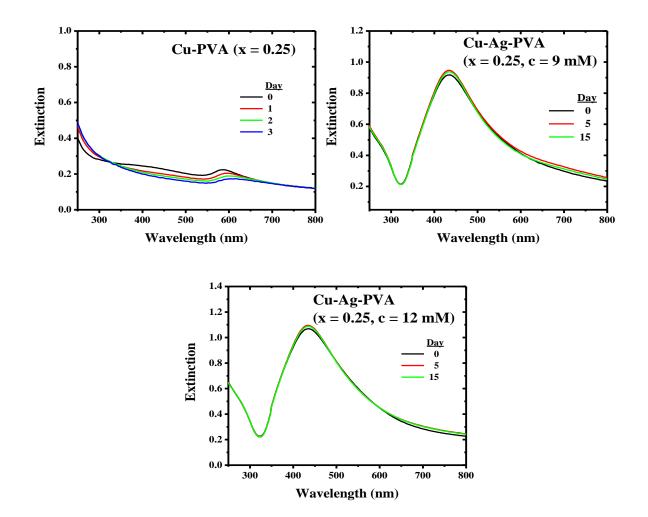


Figure S9. XPS spectra of CuO-PVA, Cu-PVA and Cu-Ag-PVA thin films.

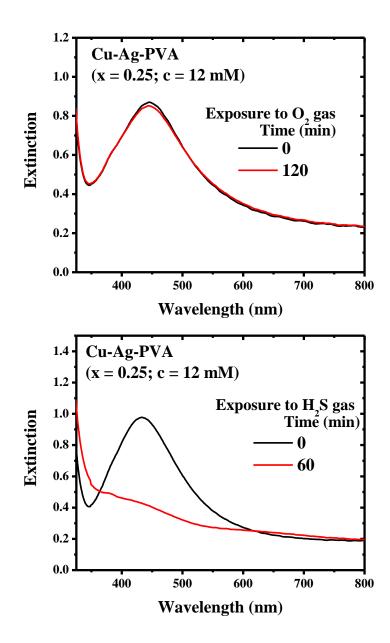
Cu-PVA film shows $2p_{3/2}$ and $2p_{1/2}$ peaks of Cu at 932.7 and 952.4 eV; the satellite with peak at ~ 942.1 eV appears to be due to partial oxidation of the Cu in the sample (Ref. 10 of main text). **CuO-PVA** film shows broadened $2p_{3/2}$ and $2p_{1/2}$ peaks with maxima at 933.1 and 953.1 eV and the satellite with peak at ~ 940.1 eV; the broader peak is associated with the formation of Cu(II). **Cu-Ag-PVA** film shows the Cu $2p_{3/2}$ and $2p_{1/2}$ peaks at 933.1 and 953.0 eV and a weak satellite peak at ~ 940.6 eV; peak due to Ag $3d_{5/2}$ is observed at 368.8 eV. The shift in energies observed for the peaks with respect to Cu(0) and Ag(0) possibly arise due to the presence of each other.

Figure S10. Extinction spectra of Cu-PVA and Cu-Ag-PVA films recorded over different time intervals.



The spectra indicate clearly the improved stability of the Cu-Ag-PVA thin film, compared to the Cu-PVA thin film.

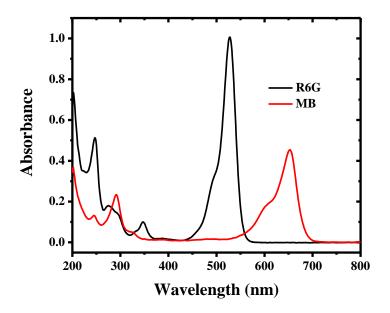




The spectra indicate clearly, that the Cu-Ag-PVA thin film is stable upon exposure to O_2 gas, whereas it is unstable under H_2S gas.

Absorption Spectra of R6G and MB

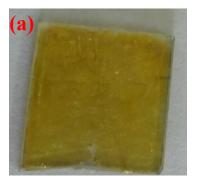


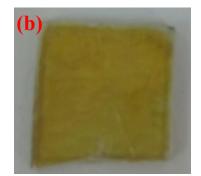


Absorption of Analyte on Cu-Ag-PVA Thin Films

Uniform absorption of the analyte on the Cu-Ag-PVA thin films was confirmed by recording the Raman spectrum at different points on the thin film. Photographs of the film without and with R6G spread and absorbed on it, are shown below; appearance of the film changes only very slightly, as the concentration of the analyte is extremely low.

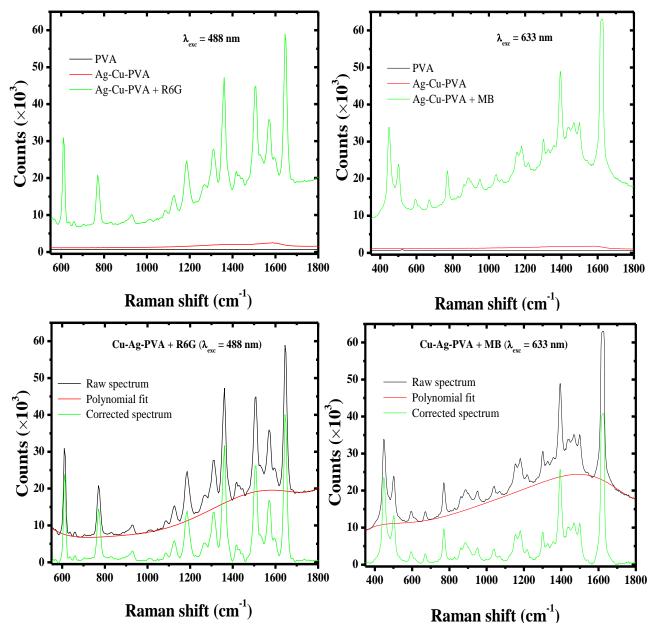
Figure S13. Photographs of Cu-Ag-PVA thin film (x = 0.25; c = 6 mM) on a glass substrate (a) without and (b) with R6G solution (~ 16 μ M) absorbed.





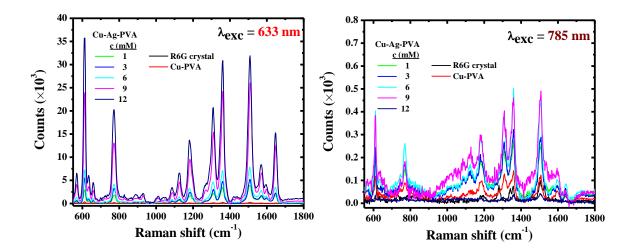
Raman Spectra of PVA, Cu-Ag-PVA and Cu-Ag-PVA with R6G and MB

Figure S14. Raman spectra of PVA and Cu-Ag-PVA (without and with R6G (8.6 μ M) and MB (6.3 μ M)) thin films, recorded using 488 and 633 nm laser excitation. The raw and corrected (for background due to fluorescence) spectra of Cu-Ag-PVA with R6G and MB are also shown.



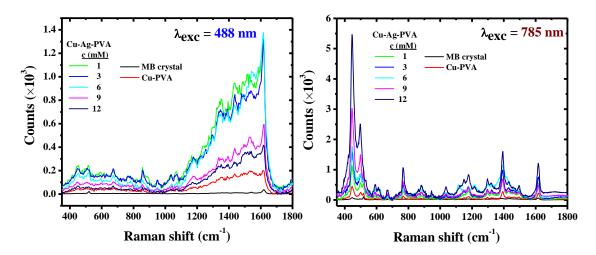
Raman Spectra of R6G

Figure S15. Raman spectra of R6G solution (8.6 μ M) on Cu-PVA (x = 0.25) and Cu-Ag-PVA thin films fabricated by treatment of the Cu-PVA with different concentrations (c) of AgNO₃, using 633 and 785 nm lasers as excitation.



Raman spectra of MB

Figure S16. Raman spectra of MB solution (6.3 μ M, 20 μ L) on Cu-PVA (x = 0.25) and Cu-Ag-PVA thin films fabricated by treatment of the Cu-PVA with different concentrations (c) of AgNO₃, using 488 and 785 nm lasers as excitation.



Calculation of SERS Enhancement Factor

Laser spot diameter,
$$W_o = \frac{1.22\lambda}{NA}$$
 Focal depth: $Z_o = \left(\frac{2\pi}{\lambda}\right) W_o^2$
Focal volume: $\tau = \left(\frac{\pi}{2}\right)^{1.5} W_o^2 Z_o$

 $N_{bulk} = ((Focal volume * Density)/ (Molecular weight))*N_A$

 $N_{SERS} = (Laser spot area/Substrate area) * (N_A * Volume * Concentration)$

$$\frac{N_{bulk}}{N_{SERS}} = \frac{\left(\frac{\pi}{2}\right)^{1.5} w_o^2 \left(\frac{2\pi}{\lambda}\right) w_o^2 \frac{\rho}{M} N_A}{\frac{\pi}{4} w_o^2 \frac{N_A V C}{A}} = \left(\frac{\pi}{2}\right)^{1.5} \left(\frac{8}{\lambda}\right) w_o^2 \frac{\rho}{M} \frac{A}{VC} = \frac{(2\pi)^{1.5}}{\lambda} w_o^2 A \frac{\rho}{w}$$
$$\frac{N_{bulk}}{N_{SERS}} = \frac{(2\pi)^{1.5}}{\lambda} \left(\frac{1.22\lambda}{NA}\right)^2 A \frac{\rho}{w} = 100 \times (2\pi)^{1.5} \times (1.22)^2 \frac{\lambda}{NA^2} \times A \times \frac{\rho}{w} = \frac{2344\lambda}{NA^2} \times A \times \frac{\rho}{w}$$

 λ = Wavelength of the laser light (nm)

NA = Numerical Aperture = 0.4

A =Area of the film (cm²) = 3

 ρ = Density of the analyte crystal (g cm⁻³)

 $\rho_{\rm R6G} = 1.28$

 $\rho_{\rm MB} = 0.98$

w = Weight of the analyte present in the solution spread on the film (ng)

 $w_{\rm R6G} = 82.39$

 $w_{\rm MB} = 40.3$

SERS enhancement factor = $(N_{BULK} / N_{SERS}) * (I_{SERS} / I_{BULK})$

Table S6. Values of (N_{BULK} / N_{SERS}) and I_{BULK} for R6G and MB used in the SERS experiments with different laser excitations.

2 (2020)	N _{BULI}	$_{\rm X}$ / N _{SERS} (×10 ⁵)	R6G		MB	
λ_{exc} (nm)	R6G	MB	Peak (cm ⁻¹)	IBULK	Peak (cm ⁻¹)	I _{BULK}
488	3.33	5.22	1645	58.72	1620	37.09
633	4.32	6.77	1509	86.30	1620	78.95
785	5.36	8.39	1506	99.00	445	74.59

Table S7. SERS enhancement factor (EF) for R6G on Cu-Ag-PVA thin film substrates fabricated by spreading different concentrations (c) of AgNO₃ on Cu-PVA (x = 0.25) thin films (a microcrystal of R6G is used as reference); data for Ag-PVA (with Ag/PVA weight ratio = 1.0, formed by heating as well as hydrazine treatment) substrate are also shown in the case of $\lambda_{exc} = 488$ nm.

(a) λ_{exc} : 488 nm

Substrate		I ₁₆₄₅	I _{SERS} /I _{BULK}	EF (×10 ⁸)
Cu-PVA		1137	19	0.06
Cu-Ag-PVA	1	7180	122	0.41
[c (mM)]	3	13643	232	0.77
	6		431	1.44
	9	31169	531	1.77
	12	40063	682	2.27
Ag-PVA	Heating	8381	143	0.48
	Hydrazine	15140	258	0.86

[I = intensity of the aromatic C-C stretch vibration : microcrystal at 1645 cm⁻¹ (I = 58.72)]

(b) λ_{exc} : 633 nm

Substrate		I ₁₅₀₉	I _{SERS} /I _{BULK}	EF (×10 ⁸)
Cu-PVA		258	3	0.01
Cu-Ag-PVA	1	3911	45	0.19
[c (mM)]	3	5219	60	0.26
	6	7635	88	0.38
	9	26110	303	1.31
	12	31904	370	1.60

[I = intensity of the aromatic C-C stretch vibration : microcrystal at 1509 cm⁻¹ (I = 86.30)]

(c) λ_{exc} : 785 nm

Substrate	:	I ₁₅₀₇	I _{SERS} /I _{BULK}	EF (×10 ⁸)
Cu-PVA		123	1	0.01
Cu-Ag-PVA	1	256	3	0.02
[c (mM)]	3	288	3	0.02
	6	451	5	0.03
	9	491	5	0.03
	12	40	0.4	0.002

[I = intensity of the aromatic C-C stretch vibration : microcrystal at 1506 cm⁻¹ (I = 99.00)]

Table S8. SERS enhancement factor (EF) for MB on Cu-Ag-PVA thin film substrates fabricated by spreading different concentrations (c) of AgNO₃ on Cu-PVA (x = 0.25) thin films (a microcrystal of MB is used as reference); data for Ag-PVA (with Ag/PVA weight ratio = 1.0, formed by heating as well as hydrazine treatment) substrate are also shown in the case of $\lambda_{exc} = 633$ nm.

(a) λ_{exc} : 488 nm

Substrate		I ₁₆₂₀	I _{SERS} /I _{BULK}	EF (×10 ⁸)
Cu-PVA		200	5	0.03
Cu-Ag-PVA	1	1295	35	0.18
[c (mM)]	3	1192	32	0.17
	6	1376	37	0.19
	9	593	16	0.08
	12	417	11	0.06

[I = intensity of the aromatic C-C stretch vibration : microcrystal at 1620 cm⁻¹ (I = 37.09)]

(b) λ_{exc} : 633 nm

Subst	rate	I ₁₆₂₀	I _{SERS} /I _{BULK}	EF (×10 ⁸)
Cu-PVA		611	8	0.05
Cu-Ag-PVA	1	15933	202	1.37
[c (mM)]	3	24310	308	2.09
6		27594	350	2.37
	9	35464	449	3.04
	12	40687	515	3.49
Ag-PVA	Heating	977	12	0.08
	Hydrazine	2637	33	0.22

[I = intensity of the aromatic C-C stretch vibration : microcrystal at 1620 cm⁻¹ (I = 78.95)]

(c) λ_{exc} : 785 nm

Substrate		I ₄₄₅	I _{SERS} /I _{BULK}	EF (×10 ⁸)
Cu-PVA		453	6	0.05
Cu-Ag-PVA	1	1136	15	0.13
[c (mM)]	3	1640	22	0.18
	6	1777	24	0.20
	9	3026	41	0.34
	12	5467	73	0.61

[I = intensity of the C-N-C deformation vibration : microcrystal at 445 cm⁻¹ (I = 74.59)]

Comparison of Enhancement Factors

Table S9. Comparison of the SERS EF of Cu-Ag based substrates reported earlier for different analytes using different excitation wavelengths with the present observations.

Ref. No	λ_{exc} (nm)	Analyte	EF (×10 ⁶)
4	514	R6G	*
11	514	R6G	1.1
12	785	Fluoranthene	0.21
13	633	R6G	*
14	780	Perchlorate	*
15	514	R6G	1.15
16	514	MBO	0.001
17	532	R6G	*
18	633	CV	*
19	514	R6G	1.0
20	532	R6G	2.5
21	633	4-ABT	1.4
22	514	CV	240
23	532	R6G	*
25	532	R6G	*
26	785	4-MBA	0.37
27	514	R6G	10.0
Present	488	R6G	227
1 resent	633	MB	349

- *Absolute value of EF is not reported
- R6G : Rhodamine 6G
- MBO : 2-mercaptobenzoxazole
- CV : Crystal violet
- MB : Methylene blue
- 4-ABT : 4-aminobenzenethiol
- 4-MBA: 4-mercaptobenzoic acid

Limit of Detection

Standard deviation was estimated using Raman spectra recorded at 5 different positions on a substrate. The limit of detection was estimated as follows.

R6G on Cu-Ag-PVA (c = 12 mM) [Fig. 10c (main text)]

Least square fit line: Counts $(\times 10^3) = 230.6 + 4771.5 \times [R6G]$ Slope of the least square fit line = 4771.5 μ M⁻¹ Limit of detection (LOD) = $(3 \times 52) / 4771.5 = 0.033 \mu$ M Volume of solution used = 20 μ L LOD in terms of number of mols = 20 μ L × 0.033 μ M = **0.66 pmol**

MB on Cu-Ag-PVA (c = 12 mM) [Fig. 10d (main text)]

Least square fit line: Counts $(\times 10^3) = 185.4 + 5943.6 \times [MB]$ Slope of the least square fit line = 5943.6 μ M⁻¹ Limit of detection (LOD) = $(3 \times 31) / 5943.6 = 0.016 \mu$ M Volume of solution used = 20 μ L LOD in terms of number of mols = 20 μ L × 0.016 μ M = **0.32 pmol**